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**MOLECULAR IMPRINTS SELLS NANO-LITHOGRAPHY SYSTEMS IN S. KOREA
AND TO A GLOBAL ELECTRONICS COMPANY IN N. CALIFORNIA**

AUSTIN, TX, February 10, 2004 – Molecular Imprints, Inc. (MII), the leading manufacturer of step and flash (S-FIL*) imprint lithography equipment, continues to prove the capabilities of its systems with the latest sales of its Imprio* 100 tool to South Korea's new National Nanofab Center at the Korea Institute of Science and Technology, as well as to a global electronics company headquartered in Northern California. The Imprio 100 system represents the next generation in nano-lithography. This tool delivers high resolution, sub-micron alignment, and 3-dimensional replication, to customers seeking cost-effective, sub-100nm lithography. The Imprio 100 can handle up to 200mm wafers, with fine alignment to 250nm, 3 sigma.

"We are very excited that these two leading customers are using our S-FIL technology in their latest research and development," said Dr. Norm Schumaker, CEO of Molecular Imprints. "These purchases provide strong customer validation of our advanced performance and signify a new, long-awaited era in lithography, which has the potential to revolutionize electronic products and applications. In addition to providing the best nano-imprint technology, MII's goal is to now offer process extendibility and support that can enable device features down to 30nm for a variety of applications such as CMOS processing, photonics, bio devices and many others".

About Molecular Imprints Inc.

Molecular Imprints, Incorporated (MII) is developing and manufacturing nano-lithography systems for high resolution and for 3-dimensional pattern replication. The company has commercialized a new and unique Step and Flash Imprint Lithography technology (S-FIL), which is a simple step and repeat, room temperature, low pressure, nano-imprint process that has demonstrated sub-20 nanometer resolution.

Molecular Imprints provides enabling lithography systems and technology for manufacturing applications in the areas of: nano-devices, micro structures, advanced packaging, bio-devices, optical components and semiconducting devices. MII's Imprio product family is a cost-effective substitute for next generation lithography systems, at a fraction of the price. For more information, visit: www.molecularimprints.com.

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